



MODIFICATION OF THE WETTABILITY OF TiO_2 SURFACES WITH ION BOMBARDMENT

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INTRODUCTION

WETTING PROPERTIES

SURFACE COMPOSITON

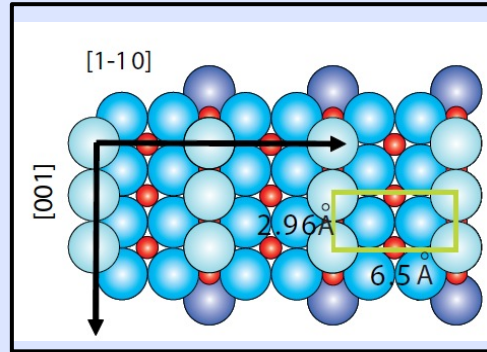
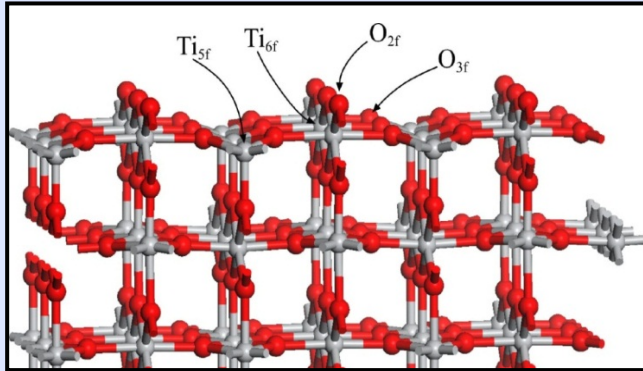
SURFACE ROUGHNESS

MICRON, Cassie, Wenzel, superhydrophobity...

NANOMETER, grains, texture...

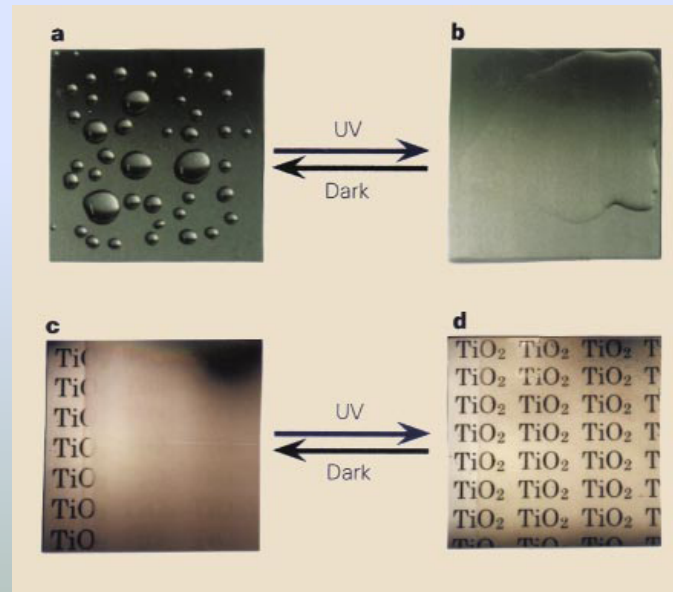
ATOMIC SCALE, vacancies, surface steps...

TiO₂(110)



- Easy to prepare
- Clean
- Stable
- Well known

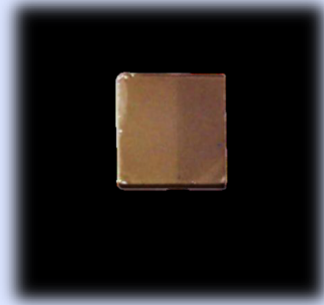
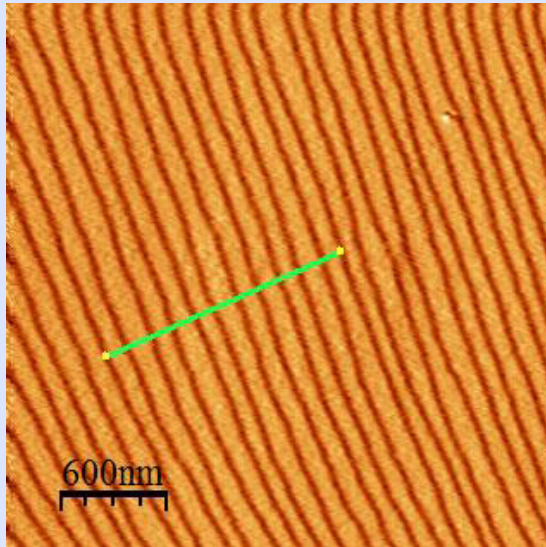
- photocatalytic
- self-cleaning



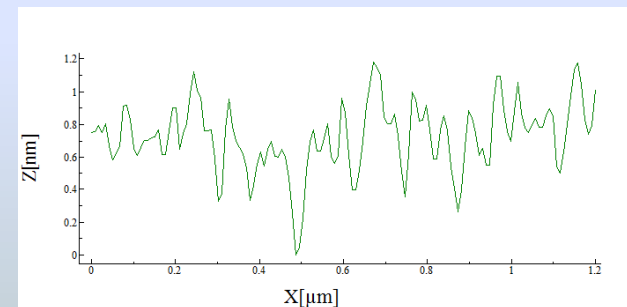
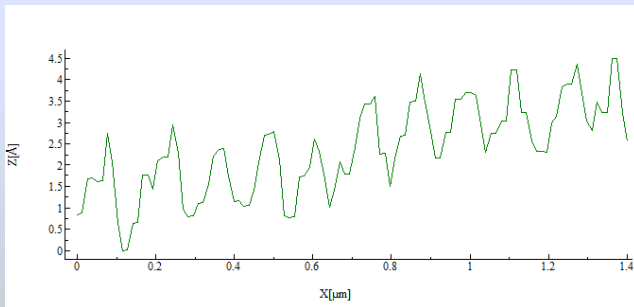
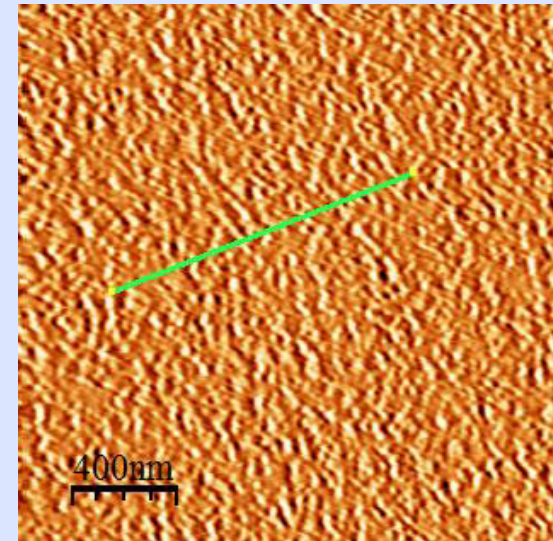
Wang *et al*, *Nature* **388**, 1997

TiO₂(110) - AFM

FLAT SURFACE



ION-BOMBARDED SURFACE



CLEANING PROCEDURE:

Immersed in HF
800 °C in air for 2h
+
Low E ion bombardment
High T annealing in 10⁻⁷ mbar O₂

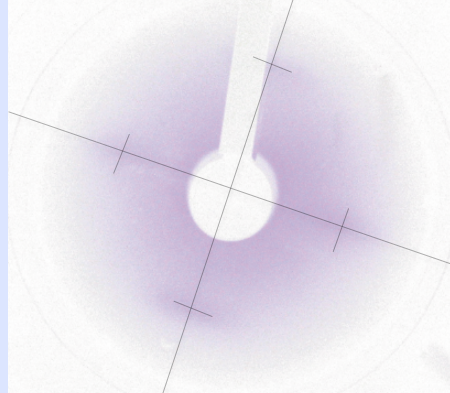
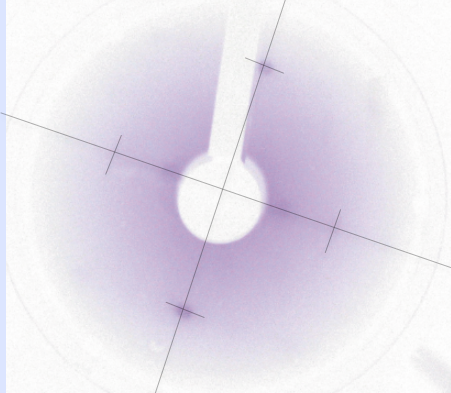
ION BOMBARDMENT:

E = 3 keV @ RT for 1h
Dose = 10¹⁷ ions/cm²

modified TiO₂(110) – LEED

FLAT SURFACE

ION-BOMBARDED SURFACE



E=63 eV

spot (2,0):

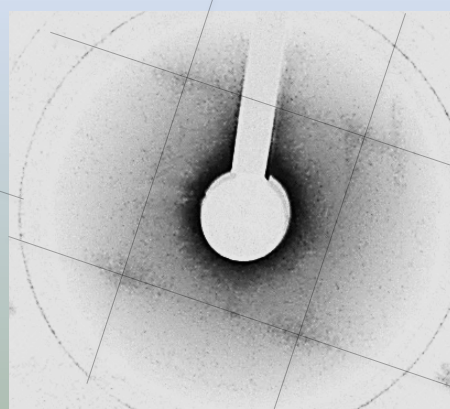
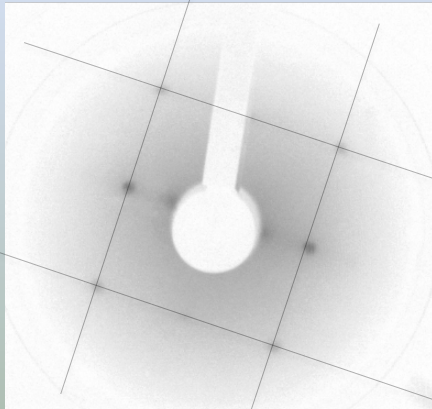
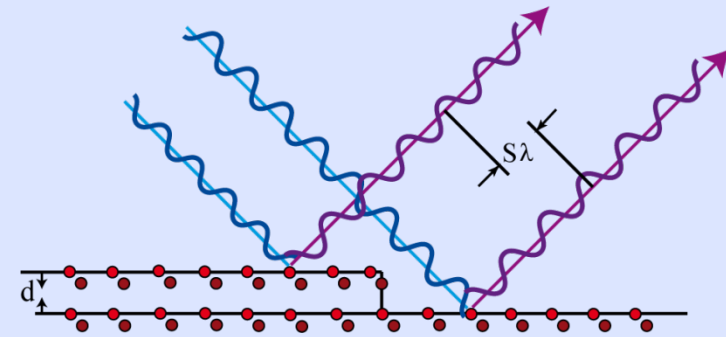
S=4.02

spot (0,1):

S=3.96

Scattering phase:

$$S = k_{\perp} d / 2\pi$$



E=95 eV

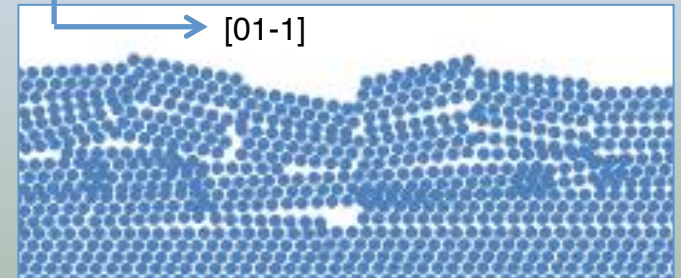
spot (2,1):

S=4.76

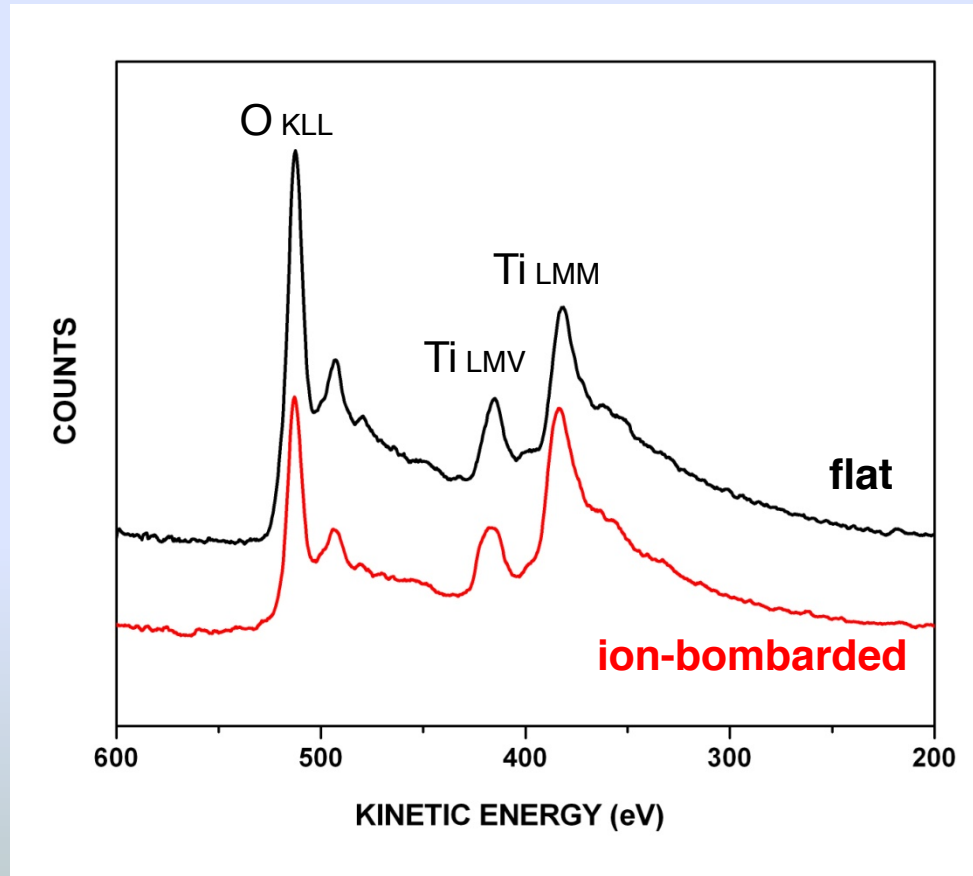
[110]

Mosaic texture tilted around the [001] axis

[01-1]



modified TiO₂(110) - Auger Electron Spectroscopy

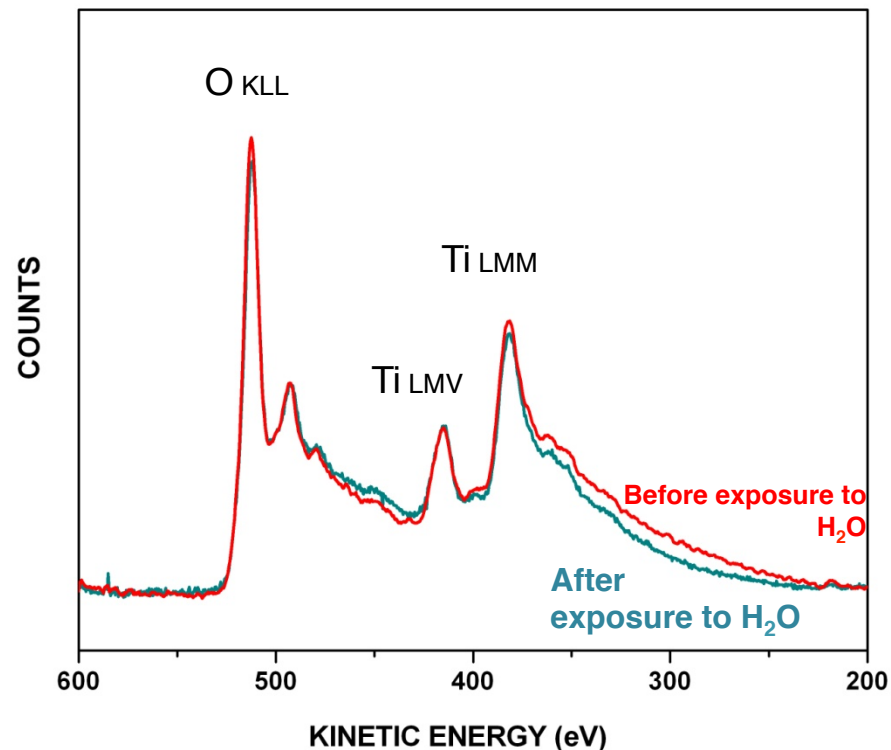
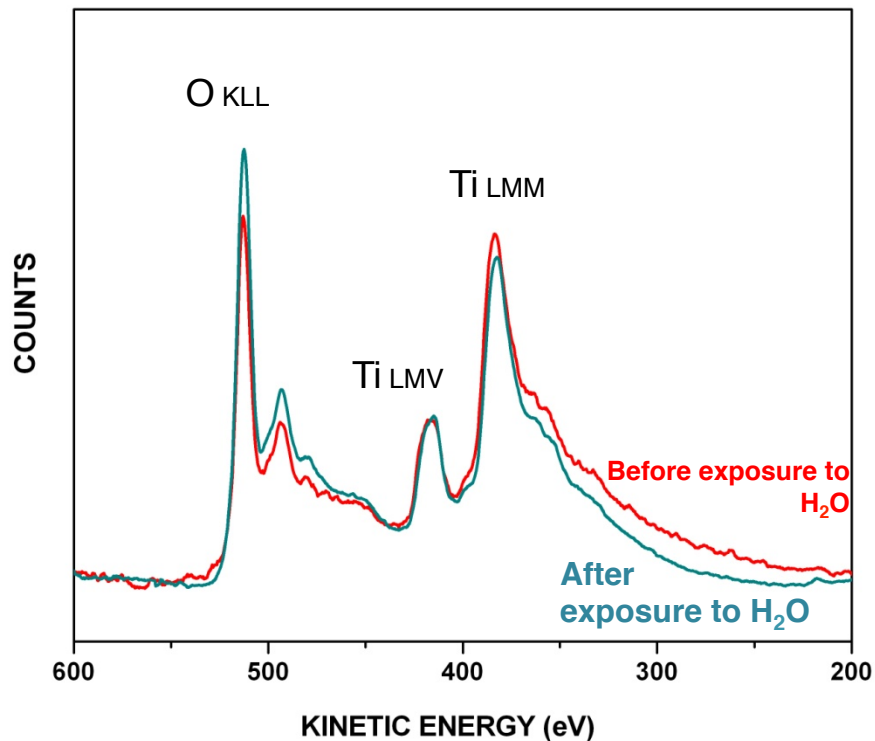


PREFERENTIAL SPUTTERING OF OXYGEN AND REDUCTION OF THE Ti CATIONS

modified TiO₂(110) - Auger Electron Spectroscopy

ION-BOMBARDED SURFACE

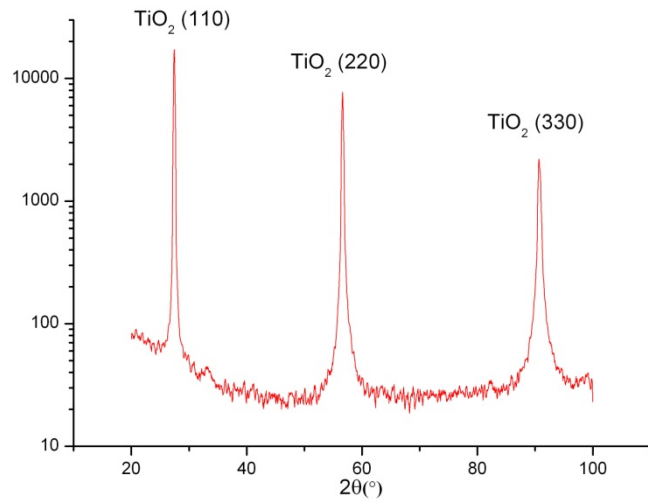
FLAT SURFACE



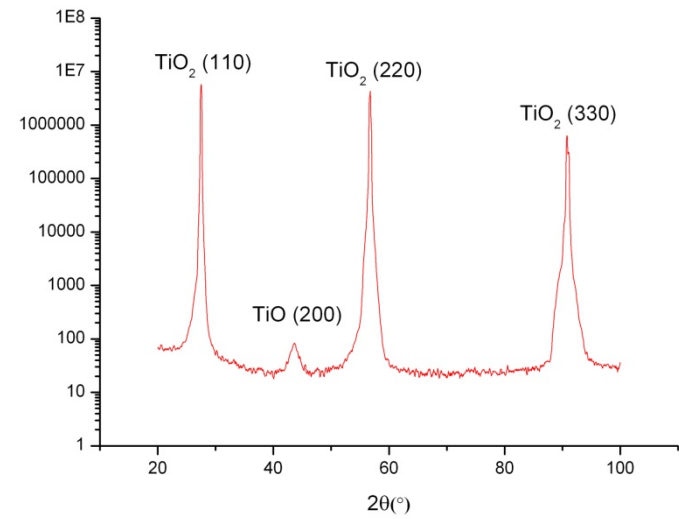
PARTIAL REOXIDATION (HYDROXYLATION) OF THE UPPER LAYER AFTER WATER EXPOSURE

modified TiO₂(110) – X Ray Diffraction

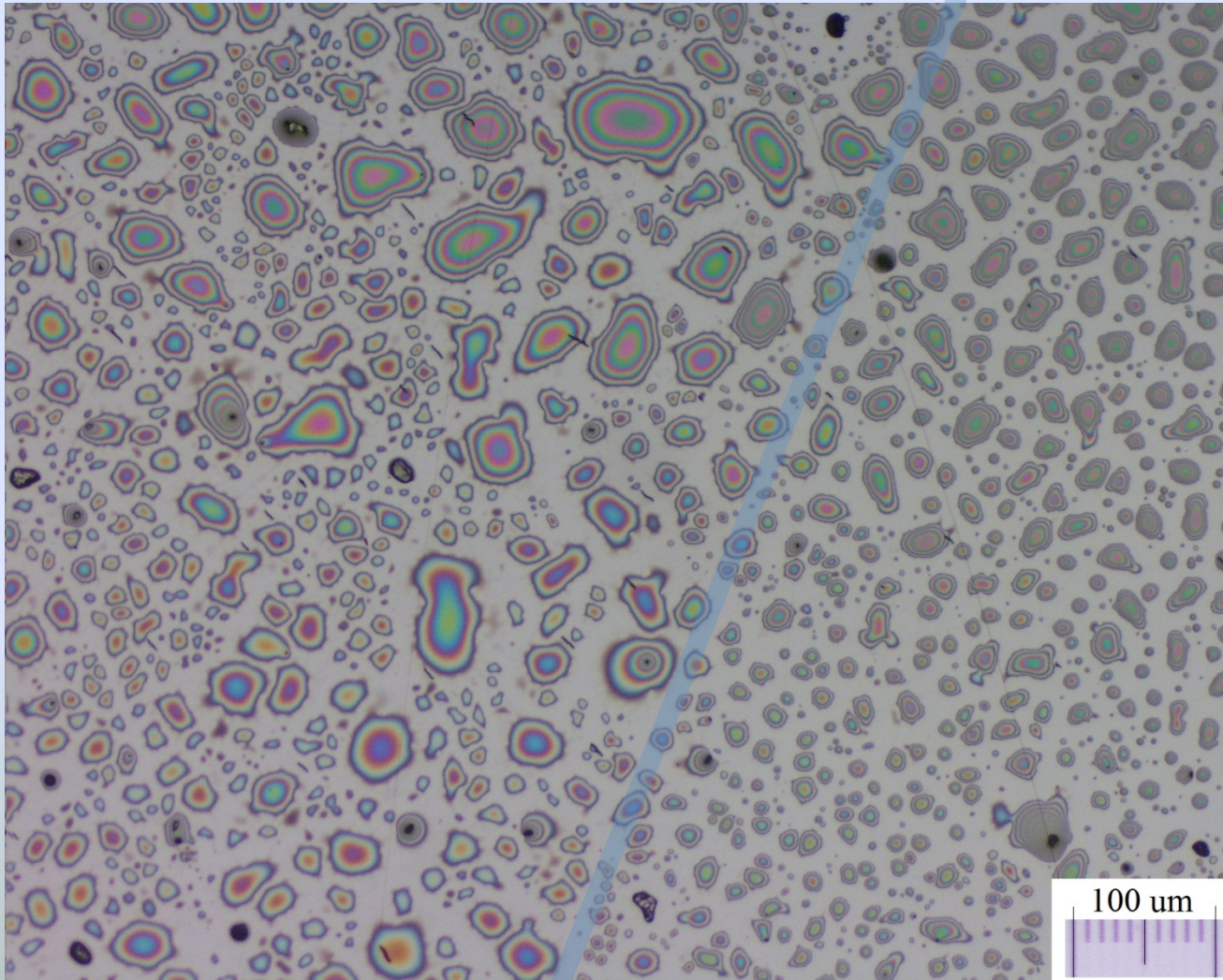
FLAT SURFACE



ION-BOMBARDED SURFACE



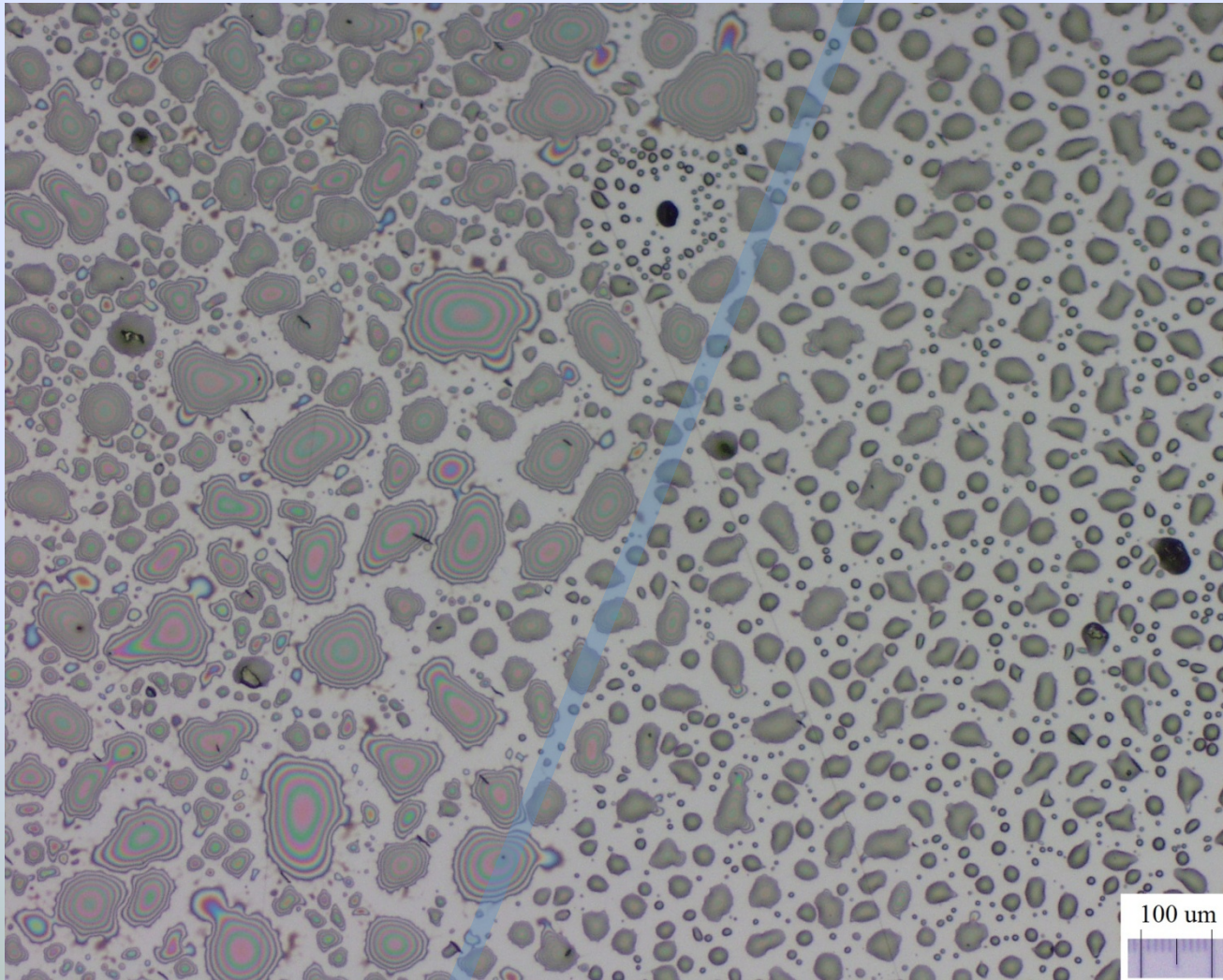
WATER CONDENSATION



Flat region

Ion bombarded region

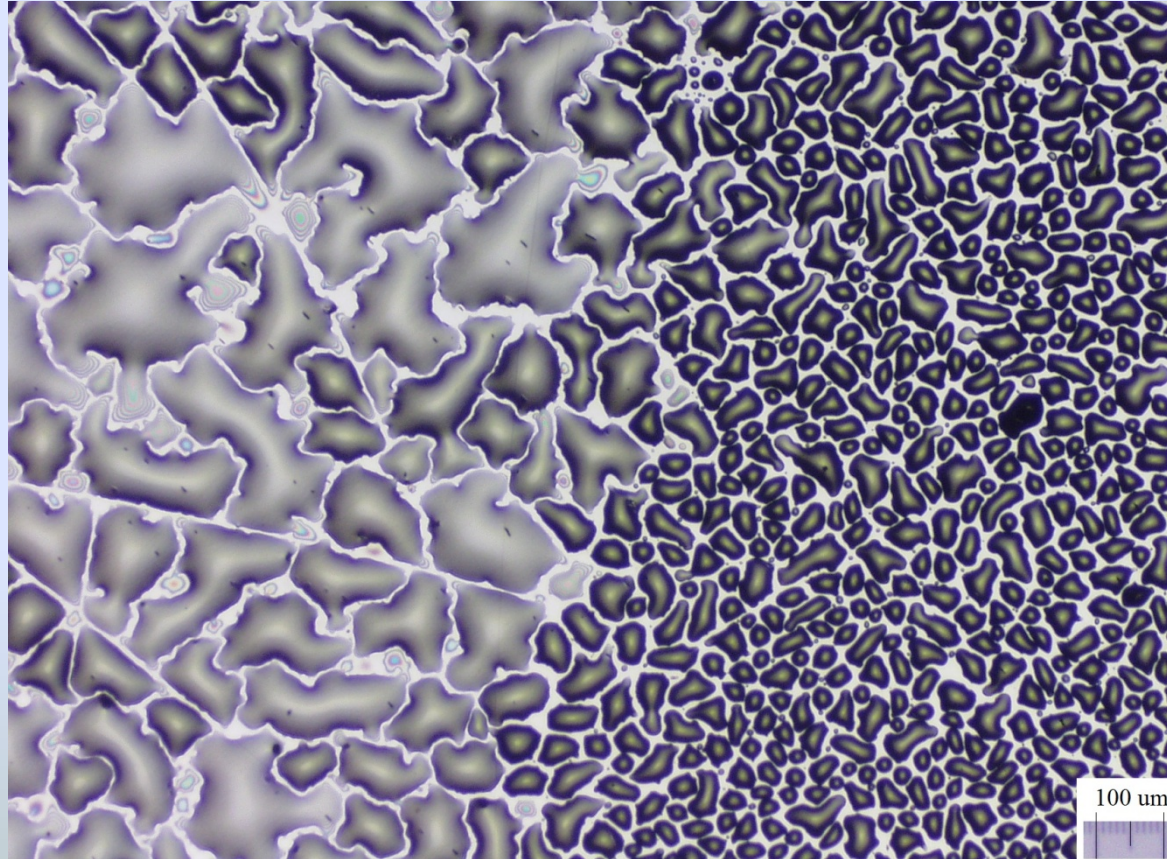
WATER CONDENSATION



Flat region

Ion bombarded region

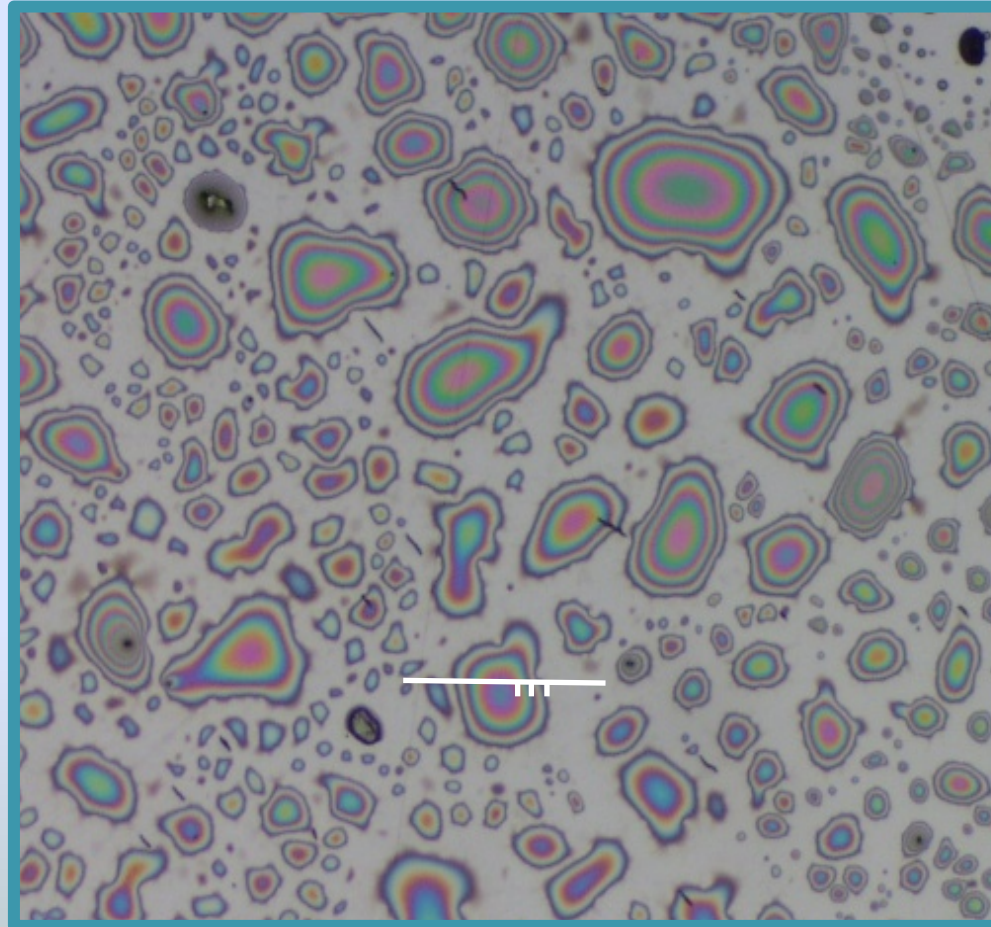
WATER CONDENSATION



Flat region

Ion bombarded region

WATER CONDENSATION

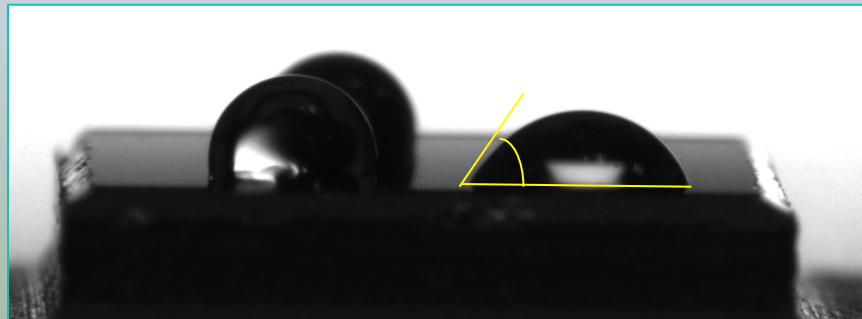
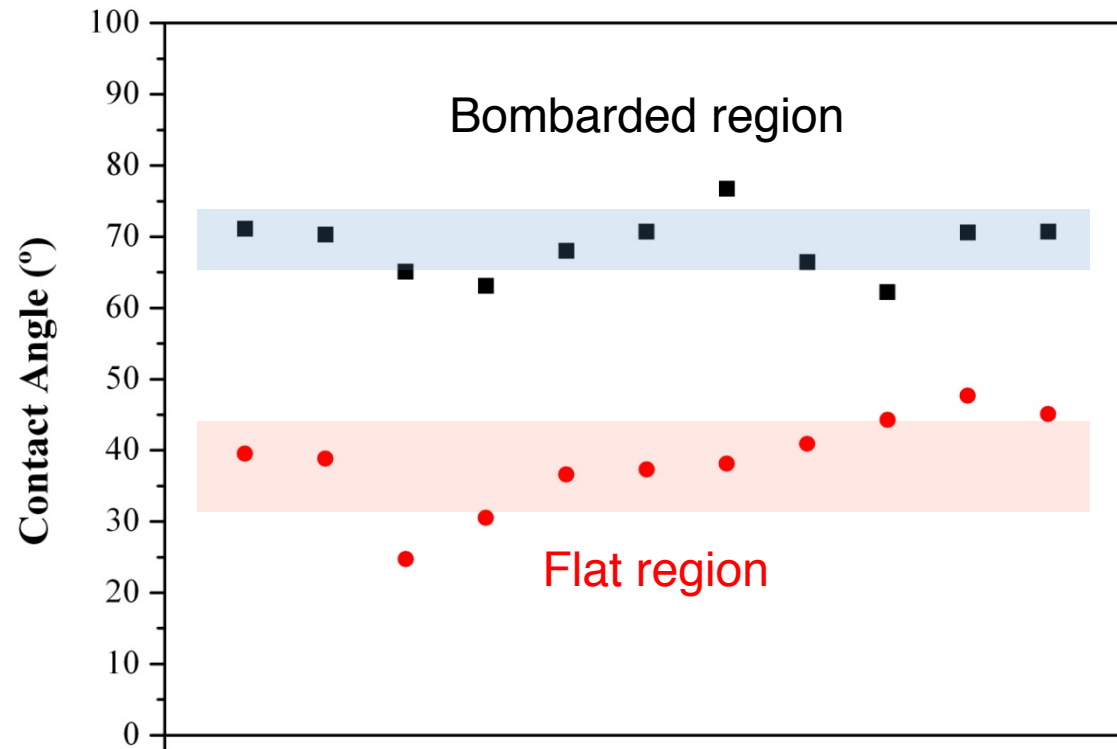


$$h = i\lambda/2n$$

$$a \approx 2^\circ$$

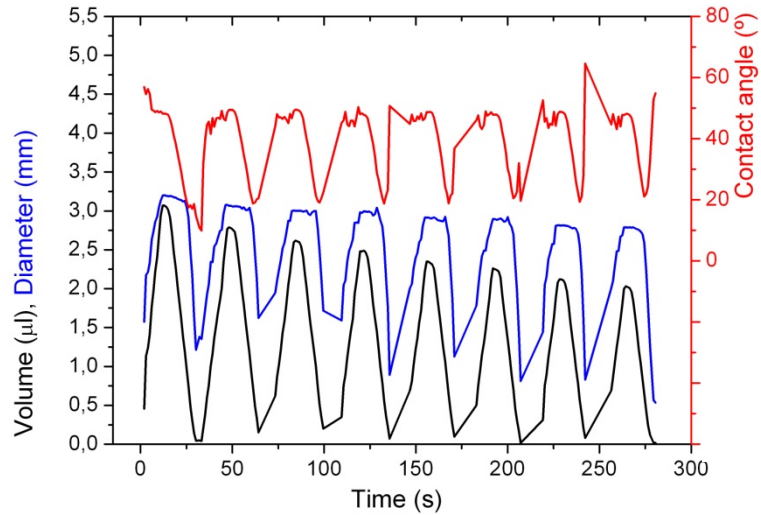
Optical interference fringes

CONTACT ANGLE

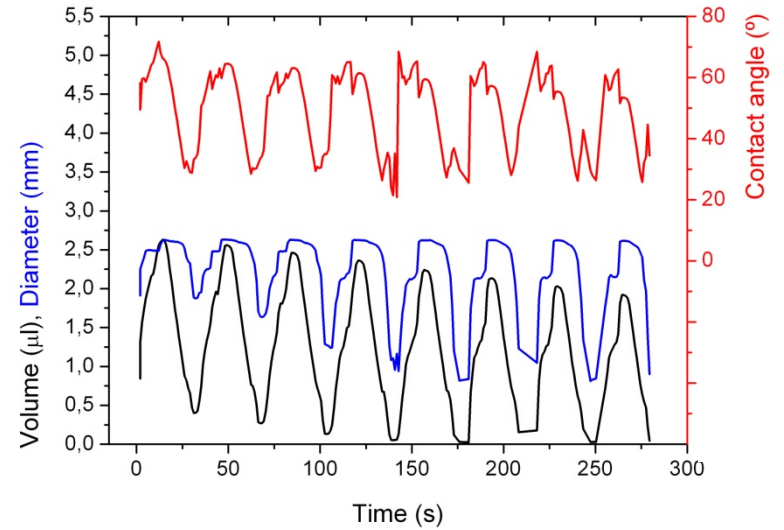


CONTACT ANGLE - DYNAMIC MEASUREMENTS

FLAT SURFACE



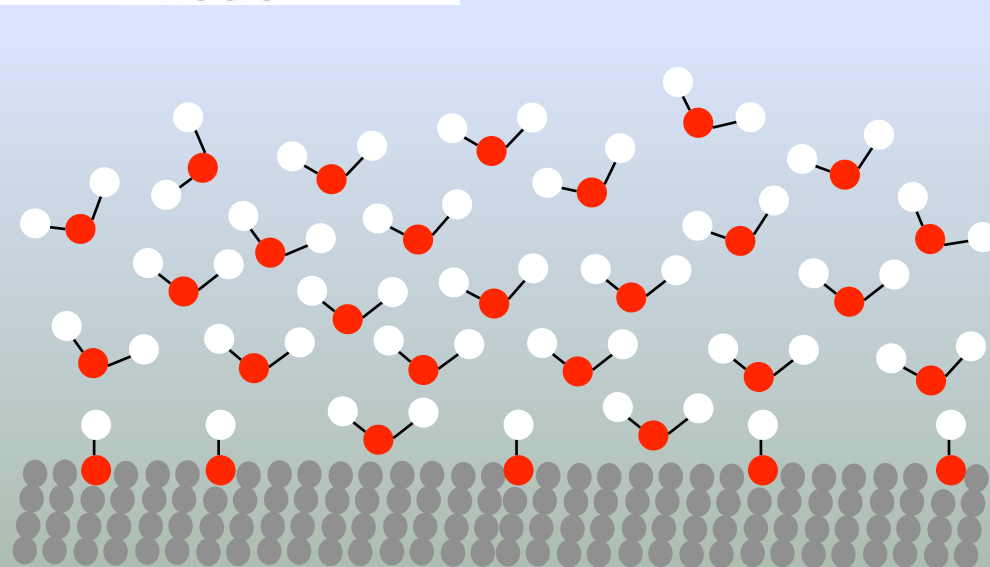
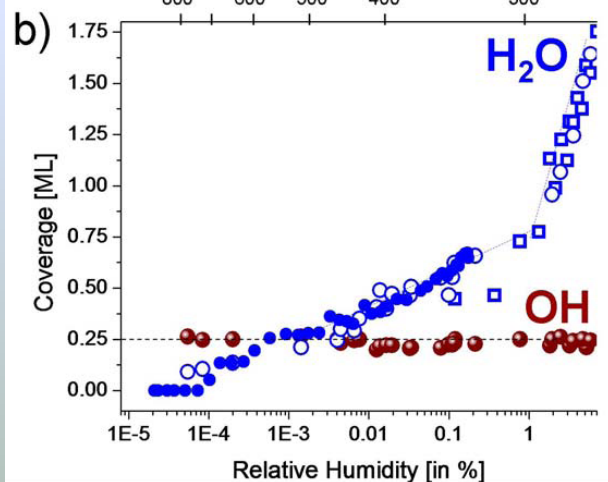
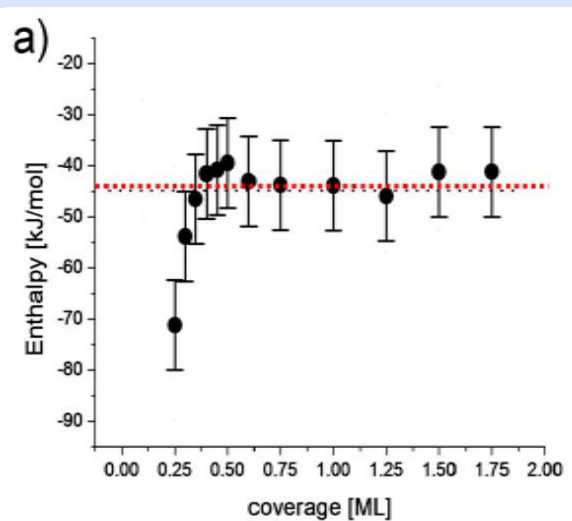
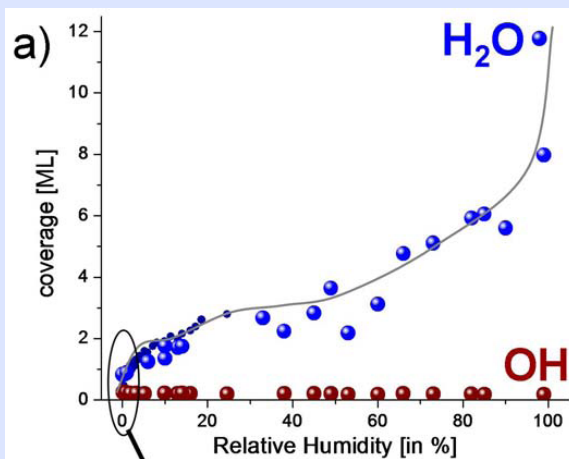
ION-BOMBARDED SURFACE



$$\gamma_{SV} = \gamma_{SL} + \gamma \cos \theta_{eq}$$

DISCUSSION

OH^- are the precursors for H_2O adsorption in defective TiO_2



CONCLUSIONS

Low energy ion bombardment of $\text{TiO}_2(110)$ causes atomic disorder and chemical reduction of the surface and a structural tilting of small regions around the [001] axis.

Exposure to water partially reoxidizes the upper layer.

When continuously exposed to water vapour, the density of nucleation points of microdroplets is larger for the flat surface, where they lie with a lower angle than in the defective surface.

After coalescence and saturation, the microdroplets are finally larger in the flat surface.

The as-placed static contact angle, as well as the advancing and receding angles in dynamic measurements, are higher for the defective surface.

This can be due in part to the formation of a non-favourable, frustrated, H-bond network.